

Croucher ASI: Nano Science and Technology – From Basic Science to Device Application

The third workshop of the Croucher Advanced Study Institute on Nano Science and Technology was held between 8-12 January 2007, three years after the second one. In the Croucher ASI: Nano Science and Technology - From Basic Science to Device Applications, six plenary speakers gave talks. Again, these were complimented by fourteen invited speakers from the Chinese Mainland, Taiwan, Japan, Korea and Hong Kong.



